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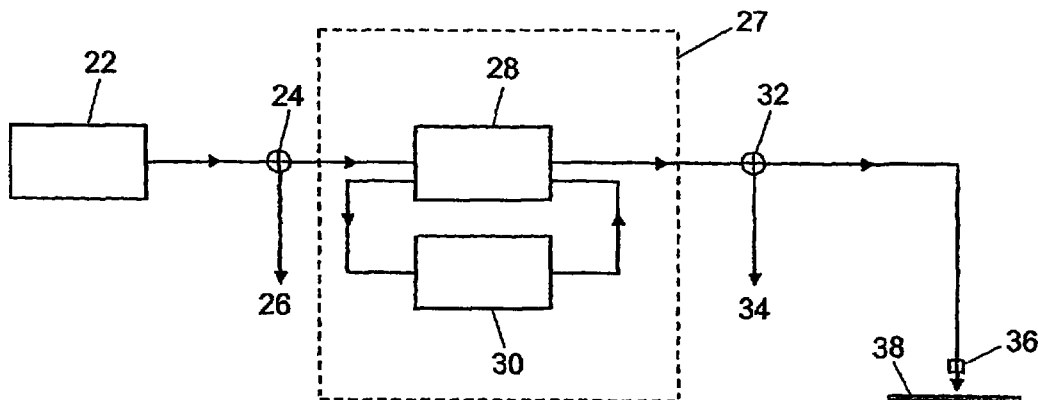
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(54) Title: A METHOD AND APPARATUS FOR TREATING A SUBSTRATE WITH AN OZONE-SOLVENT SOLUTION



(57) Abstract: A general method and apparatus for treating materials comprising the steps of dissolving ozone gas in a solvent at a predetermined temperature T1 to form an ozone solvent solution produced by the ozonated water supply (22), heating the ozone solvent solution by a heat exchanger (28) to a second predetermined temperature T2 which is greater than T1, and directing the flow of the ozone solvent solution to a dispensing nozzle (36) for treatment of the material (38).